Phase stability and transition of BaSi₂-type disilicides and digermanides

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BaSi2-type disilicides and digermanides hold great promise for solar-cell applications, but their structural stability and phase transition mechanisms remain unresolved. Here we present *ab initio* calculations of pressureinduced structural phase transitions of BaSi₂, BaGe₂, and SrGe₂ and show that Si tetrahedra in orthorhombic BaSi2 tend to convert to corrugated layers in the trigonal phase under high pressure with bond breaking along the *b* axis, and a three-dimensional Si net in the cubic phase is stabilized energetically at low pressure. The orthorhombic semiconductor–to–trigonal metal conversion is also preferred for $SrGe₂$ both energetically and kinetically. However, Ge tetrahedra in BaGe₂ tend to convert to a ThSi₂-type tetragonal net with bond breaking around the *c* axis. The kinetic barriers are large for both the reaction (∼0*.*43 eV under compression) and the counter-reaction (∼0.39 eV under decompression) for BaSi₂, which explains the stability of the trigonal and cubic phases at room temperature and the high-temperature requirement for the phase transitions.

The BaSi₂-type disilicides and digermanides $BaSi₂$, $SrSi₂$, $BaGe₂$, and $SrGe₂$ are semiconductors with larger band gaps, 0.9–1.3 eV, and high optical absorption coefficients $[1-4]$, which make them ideal candidates as silicon-based solar cell materials. Great interest in these materials has been reignited by the recent success in preparing well-crystalline *a*-axis-oriented BaSi₂ and Ba_{1−*x*}Sr_{*x*}Si₂ epitaxial films on $Si(111)$ and $Si(100)$ substrates $[5–10]$. It was demonstrated that the electronic band gap can reach the ideal value of approximately 1.4 eV by replacing half of the Ba atoms with isoelectric Sr atoms [\[5\]](#page-4-0). Meanwhile, there is a rich variety of pressure-induced structural phase transitions similar to those observed in Si and Ge [\[11\]](#page-4-0). Under ambient conditions, $BaSi₂$, $BaGe₂$, and $SrGe₂$ all adopt the $BaSi₂$ -type orthorhombic structure, but $SrSi₂$ has the $SrSi₂$ -type cubic structure [\[12–19\]](#page-4-0). Under high-pressure and high-temperature (HPHT) conditions, orthorhombic $BaSi₂$ transforms into $SrSi₂$ -type cubic and EuGe₂-type trigonal structures $[20-22]$, and the trigonal phase can exist under ambient conditions, showing a metallic and superconducting behavior [\[23\]](#page-4-0). On the other hand, orthorhombic $BaGe₂$ and $SrGe₂$ [\[17,24,25\]](#page-4-0) transform into tetragonal and trigonal structures, respectively. Each phase of disilicides and digermanides is characterized by a unique three-connected Si or Ge configuration: isolated tetrahedra in the orthorhombic phase; two-dimensional, threeconnected (2D3C) corrugated layers in the trigonal phase; and three-dimensional, three-connected (3D3C) nets in both cubic and tetragonal phases. As far as we know, a metallic phase formed under high pressure rarely exists at atmospheric pressure and room temperature. Past studies have explored the electronic, thermoelectric, and optical properties of these materials [\[26–28\]](#page-4-0), but the more complicated and important atomistic mechanisms for the phase stability and pressureinduced phase transformations remain unresolved.

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In this paper, we present a comprehensive study of the phase stability and transition of $BaSi₂$ compared with $BaGe₂$ and $SrGe₂$ over the wide pressure range of 0–10 GPa. We examine the energetics and kinetics that govern the phase stability and drive the structural conversion. In particular, we identify the pathways from the tetrahedral configurations in the orthorhombic phase toward the 2D3C corrugated layers in the trigonal phase and the 3D3C nets in the cubic phase with the Si-Si bond breaking and reconstruction parallel to the $b[010]$ axis. Si tetrahedra in orthorhombic $BaSi₂$ convert to corrugated layers dynamically under high pressure, which further convert to 3D3C cubic nets under low pressure (*<*7 GPa) driven by energetics. Direct conversion from the orthorhombic (semiconductor) to the trigonal (metal) structure is also favored for $SrGe₂$ by both energetics and kinetics. Moreover, Ge tetrahedra in $BaGe₂$ tend to form a 3D3C tetragonal net structure with bond breaking and rebonding around the *c*[001] axis. Pressure plays a key role in enhancing the high-pressure phase stability, but it has little effect on the conversion barrier. The large counter-reaction barriers (∼0*.*39 eV) are comparable to the compression process reaction barriers (∼0.43 eV) for BaSi₂, which explains the high stability of the HPHT metastable (cubic or trigonal) phases at room temperature and the requirement of high temperature for the phase transitions [\[20\]](#page-4-0), in contrast to the low-kinetic-barrier, cold-compressed phase transitions in Si and Ge [\[11\]](#page-4-0).

Our calculations are carried out using density functional theory as implemented in the Vienna *ab initio* simulation package (VASP) [\[29\]](#page-4-0) with the spin-polarized generalized gradient approximation [\[30\]](#page-4-0). The all-electron projector augmented wave (PAW) method [\[31\]](#page-4-0) was adopted, with $4s^24p^65s^2$ for Sr, $5s^25p^66s^2$ for Ba, $3s^23p^2$ for Si, and $3d^{10}4s^24p^2$ for Ge treated as valence electrons. A planewave basis set with an energy cutoff of 500 eV was used. The phase conversion barrier was calculated using a generalized solid-state nudged elastic band method [\[32\]](#page-4-0) with cell and atomic position optimization. Forces on the ions are calculated through the Hellmann-Feynman theorem,

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FIG. 1. (Color online) Energy versus volume per atom for $BaSi₂$ (a), $BaGe₂$ (c), and $SrGe₂$ (e). Enthalpy per atom versus pressure for BaSi₂ (b), BaGe₂ (d), and SrGe₂ (f), relative to that of a BaSi₂type orthorhombic structure. The BaSi₂-type orthorhombic (ort), SrSi₂-type cubic (cub), *α*-ThSi₂-type tetragonal (tet), and EuGe₂-type trigonal (tri) phases are in D_{2h}^{16} -*Pnma*, O^6 -*P*4₃32, D_{4h}^{19} -*I*4₁/amd, and D_{3d}^3 - P_{3m}^3 1 symmetry, respectively. The enthalpy of a CaSi₂-type structure ($tr6$ in $R\overline{3}m$ symmetry) [\[22\]](#page-4-0) is shown for comparison.

allowing a full geometry optimization. Convergence criteria employed for both the electronic and the ionic relaxation were set to 10^{-6} eV and 0.02 eV/Å for energy and force, respectively.

We first discuss the energetic stability of silicides and germanides. The results show that the most favorable structures are orthorhombic, with the relatively large volumes of 30.78, 32.53, and 28.61 \mathring{A}^3 per atom for BaSi₂, BaGe₂, and SrGe₂ [see Figs. $1(a)$, $1(c)$, and $1(e)$], respectively. Meanwhile, the second stable phases have distinct cubic, tetragonal, or trigonal structures, with the relatively small volumes of 26.43, 29.86, and 26.83 \AA^{3} per atom. Upon compression, for BaSi $_2$ as shown in Fig. $1(b)$, the cubic structure becomes more stable than the

TABLE I. Calculated equilibrium lattice parameters *a, b*, and *c* (in Å), volume (in A^3 per atom), and bulk modulus (B_0 in GPa) for BaSi₂, BaGe₂, and SrGe₂ in orthorhombic (ort), cubic (cub), tetragonal (tet), and trigonal (tri) symmetry at 0 GPa, compared to available experimental data. [\[17–19,22,24,25\]](#page-4-0)

Phase	Method	$a(\AA)$	b(A)	$c(\AA)$	$V_0(\text{\AA}^3)$	B_0 (GPa)
$BaSi2-ort$	Cal	9.224	6.827	11.716	30.78	28.23
	Exp[19,22]	8.942	6.733	11.555	28.99	27.94
$BaSi2-tri$	Cal	4.102	4.102	5.445	26.41	44.46
	Exp[19]	4.047	4.047	5.330	25.21	
$BaSi2-cub$	Cal	6.820	6.820	6.820	26.43	48.24
	Exp $[19]$	6.715	6.715	6.715	25.24	
$BaSi2$ -tet	Cal	4.736	4.736	14.287	26.71	40.84
$BaGe2-ort$	Cal	9.471	6.942	11.861	32.53	25.14
	Exp[24]	9.078	6.829	11.653	30.10	
BaGe ₂ -tri	Cal	4.344	4.344	5.435	29.59	38.60
$BaGe2-cub$	Cal	7.088	7.088	7.088	29.68	38.31
$BaGe2$ -tet	Cal	4.882	4.882	15.031	29.86	35.64
	Exp $[25]$	4.769	4.769	14.737	27.93	
$SrGe2-ort$	Cal	9.058	6.674	11.351	28.61	29.12
	Exp[17]	8.739	6.567	11.215	26.82	
$SrGe2-tri$	Cal	4.204	4.204	5.256	26.83	41.50
	Exp[18]	4.104	4.104	5.165	25.11	
$SrGe2$ -cub	Cal	6.887	6.887	6.887	27.23	41.62
$SrGe2$ -tet	Cal	4.693	4.693	14.716	27.01	39.78

orthorhombic structure at 1.9 GPa, and the trigonal structure becomes more stable than the cubic structure above 7.2 GPa. The larger enthalpy change between the orthorhombic and the cubic phases shows a strong pressure dependence with a large volume change, while the small enthalpy change between the cubic and the trigonal phases has a corresponding small volume change (see Table I). On the other hand, for $BaGe₂$ and $SrGe₂$, as shown in Figs. 1(d) and 1(f), no stable cubic phase exists up to 10 GPa. The tetragonal and trigonal structures become more stable than the orthorhombic structure above 3.2 and 0.52 GPa, respectively. The enthalpy of the $CaSi₂$ -type structure ($tr6$ in $R\overline{3}m$ symmetry) is also shown in Figs. 1(b), $1(d)$, and $1(f)$ for comparison [\[22\]](#page-4-0), but it is clearly unfavorable for $BaSi₂$, $BaGe₂$, and $SrGe₂$ over the wide pressure range of 0–10 GPa.

It is worth noting that all of the Si and Ge sublattices satisfy the (8-N) rule, which requires a formal transfer of valence electrons from the divalent metal atoms to Si or Ge atoms [\[24\]](#page-4-0), which then become isoelectronic with group V elements. One can regard BaSi₂ formally as $Ba^{2+}[Si^-]_2$, and accordingly, Si₄ tetrahedra are preferred in the orthorhombic phase, which is similar to the structural arrangement in white phosphorus [\[33\]](#page-4-0). Since the orthorhombic phases have a high compressibility with a larger volume and a smaller bulk modulus (see Table I), the more densely packed cubic, trigonal, or tetragonal phases can be produced under pressure. Here the corrugated layers of Si in the trigonal phase are similar to the crystal structures adopted by black phosphorus at high pressures [\[34\]](#page-4-0), and the cubic Si nets are congruent to the pressure-induced structure of cubic gauche nitrogen (cg-N) [\[35\]](#page-4-0).

We next examine the kinetic process at the atomic scale using a generalized solid-state climbing image nudged

elastic band method [\[32\]](#page-4-0) with cell and atomic position optimization under the wide pressure range of 0–8 GPa. According to the above results, there are three possible phase transformations from the $BaSi₂$ -type orthorhombic structure toward the $SrSi₂$ -type cubic, Th $Si₂$ -type tetragonal, and $EuGe₂$ -type trigonal phases under pressure. For transformation of the orthorhombic $BaSi₂$ to the cubic $BaSi₂$ phase [see Fig. 2(a)], $b_{\text{ort}} = 6.827 \text{ Å} \rightarrow a_{\text{cub}} = 6.820 \text{ Å},$ $c_{\text{out}} = 11.716 \text{ Å} \rightarrow \sqrt{2}a_{\text{cub}} = 9.645 \text{ Å}$, and $a_{\text{out}} = 9.224 \text{ Å} \rightarrow$ $\sqrt{2}a_{\text{cub}} = 9.645$ Å, with about -18% shortening in the c_{ort} direction and about $+4.6\%$ elongation in the a_{ort} direction. Meanwhile, four Si₄ tetrahedra convert to four fourfold helices with bond breaking along the *b*[010] direction and rebonding with torsion angles of 60◦ between the helical chains to form the 3D3C cubic net [\[36\]](#page-4-0). Throughout this pathway, the intermediate structures are all in $P2_1$ (No. 4) monoclinic symmetry, and the ∠Si-Si-Si bond angle changes from 60° in Si₄ tetrahedra to 118 $^\circ$ in fourfold helices. As a result, one orthorhombic unit cell is converted into two cubic unit cells with four fourfold helices. For transformation of the orthorhombic $BaSi₂$ into the trigonal $BaSi₂$ phase [see Fig. 2(b)], $b_{\text{ort}} = 6.827 \text{ Å} \rightarrow \sqrt{3}a_{\text{tri}} = 7.105 \text{ Å}, a_{\text{ort}} =$ 9.224 $\AA \rightarrow 2a_{\text{tri}} = 8.204 \AA$, and $c_{\text{ort}} = 11.716 \AA \rightarrow 2c_{\text{tri}} =$ 10.890 Å, with about -7% shortening in the c_{ort} , -11% shortening in the a_{ort} , and $+4\%$ elongation in the b_{ort} direction. Along this pathway, four Si4 tetrahedra convert to four distorted chains (parallel to the *b*[010] direction) with the bond breaking perpendicular to the *c*[001] axis, and then four chains rebond to each other to form corrugated Si layers with distorted six-membered rings. Throughout this pathway, the intermediate structures are all in $P2₁/C$ (No. 14) monoclinic symmetry, and the ∠Si-Si-Si bond angle changes from 60° to 111*.*6◦ . As a result, one orthorhombic unit cell turns into four hexagonal cells. On the other hand, for transformation of the orthorhombic $BaSi₂$ into the tetragonal $BaSi₂$ phase [see Fig. 2(c)], $b_{\text{ort}} = 6.827 \text{ Å} \rightarrow \sqrt{2}a_{\text{tet}} = 6.698 \text{ Å}, a_{\text{ort}} =$ 9.224 $\AA \to \sqrt{2}a_{\text{tet}} = 6.698 \AA$, and $c_{\text{ort}} = 11.716 \AA \to c_{\text{tet}} =$ 14.287 Å, with about -27% shortening in the a_{ort} direction and about $+22\%$ elongation in the c_{ort} direction. Along the pathway, four $Si₄$ tetrahedra convert to four flat $Si₄$ groups with bond breaking around the *c*[001] axis, and then the four flat Si4 groups rebond to each other to form a 3D3C tetragonal net [see Fig. $2(c)$]. Throughout this pathway, the intermediate structures are all in $P2_12_12_1$ (No. 19) orthorhombic symmetry, and the ∠Si-Si-Si bond angle changes from 60 $^{\circ}$ to 120 $^{\circ}$. As a result, one orthorhombic unit cell is converted into two tetragonal unit cells.

Figure $3(a)$ shows the enthalpy along the pathways starting from orthorhombic $BaSi₂$ toward the formation of the cubic, tetragonal, and trigonal BaSi₂ phases at 4 GPa. The enthalpy increases initially due to the bond twisting and breaking of the Si4 tetrahedra in the orthorhombic phase, and then it decreases with the relinking of Si-Si bonds. The conversion barriers are estimated to be 0.424 eV for orthorhombic \rightarrow cubic, 0.430 eV for orthorhombic \rightarrow trigonal, and 0.434 eV for orthorhombic \rightarrow tetragonal. These results suggest a strongly competitive nature to form the cubic, trigonal, and tetragonal structures. A similar competitive nature is also found in the hypothetical conversion of orthorhombic $SrSi₂$ [\[37\]](#page-4-0). Among these reactions, however, the pathway

FIG. 2. (Color online) Top and side views of the structures along the pathways to form cubic, trigonal, and tetragonal $BaSi₂$ starting from the orthorhombic phase at 4 GPa. (a) Conversion process orthorhombic \rightarrow cubic with bond breaking along the *b*[010] direction. The intermediate structures along the pathway are in *P*21 (No. 4) monoclinic symmetry. (b) Conversion process orthorhombic \rightarrow trigonal with shortening in the a_{ort} and c_{ort} directions and elongation in the *b*ort direction. The intermediate structures along the pathway are in *P*21*/C* (No. 14) monoclinic symmetry. (c) Conversion process orthorhombic \rightarrow tetragonal with shortening in the a_{ort} direction and elongation in the *c*ort direction. The intermediate structures along the pathway are in $P2_12_12_1$ (No. 19) orthorhombic symmetry. Small (blue) and large (green) circles denote Si and Ba atoms, respectively.

toward the trigonal phase has the lowest enthalpy up to step 8 as shown in Fig. $3(a)$. Thus the orthorhombic-totrigonal transition is more favored dynamically than the orthorhombic-to-cubic transition. Experimentally, a two-stage reaction process of orthorhombic \rightarrow trigonal \rightarrow cubic is shown at 5.2 GPa up to 1133 K [\[20\]](#page-4-0). To clarify this point,

FIG. 3. (Color online) (a), (c), (e) Enthalpy versus transformation pathways orthorhombic \rightarrow cubic, orthorhombic \rightarrow trigonal, and orthorhombic \rightarrow tetragonal at 4 GPa for BaSi₂, BaGe₂, and SrGe₂, respectively. (b), (d), (f) Enthalpy barriers versus pressure for orthorhombic \rightarrow cubic, orthorhombic \rightarrow tetragonal, and orthorhombic \rightarrow trigonal, respectively.

we have also examined the second-stage trigonal-to-cubic conversion process [\[37\]](#page-4-0), and the corresponding enthalpy is plotted in Fig. $3(a)$. The conversion barrier is estimated as 0.24 eV at 4 GPa, which is lower than the 0.43 eV for the firststage orthorhombic-to-trigonal conversion. Consequently, cubic $BaSi₂$ can be easily synthesized by a two-stage reaction process.

We plot in Fig. 3(b) the enthalpy barriers versus pressure. With increasing pressure from 0 to 8 GPa, the barriers undergo only small changes: from 0.429 to 0.421 eV for orthorhombic \rightarrow cubic, from 0.411 to 0.452 eV for orthorhombic \rightarrow trigonal, and from 0.430 to 0.448 eV for orthorhombic \rightarrow tetragonal. These results show that pressure has little effect on the conversion barrier, which means that these phase conversions require high temperatures to overcome the large energy barriers. This is similar to the situation of phase conversion of graphite to diamond [\[38\]](#page-4-0).

Experimentally, it has been reported that both the cubic and the trigonal phases of $BaSi₂$ can be quenched to the ambient conditions $[20]$. To clarify this point, the counterreaction barriers are also plotted in Fig. $3(b)$. With decreasing pressure from 8 to 0 GPa, the barriers decrease from 0.522 to 0.387 eV for cubic \rightarrow orthorhombic, from 0.563 to 0.369 eV for trigonal \rightarrow orthorhombic, and from 0.529 to 0.398 eV for tetragonal \rightarrow orthorhombic. These results suggest that pressure has a considerable effect on lowering the kinetic barrier upon decompression. However, the counterreaction barriers remain at high values (∼0*.*39 eV at 0 GPa) that are comparable to the barriers encountered during the compression process (∼0*.*43 eV). As a result, the cubic and trigonal phases can be stabilized under ambient conditions due to a combination of the large counter-reaction barriers (∼0*.*39 eV) and small energy differences (∼0*.*05 eV per atom) relative to the $BaSi₂$ -type orthorhombic structure [see Fig. [1\(b\)\]](#page-1-0).

For BaGe₂, as shown in Figs. $3(c)$ and $3(d)$, the orthorhombic \rightarrow tetragonal conversion is clearly favorable both kinetically and energetically. On the other hand, for $SrGe₂$ compound, the cubic structure is unfavorable in enthalpy as shown in Fig. $1(f)$ over the wide pressure range of 0–10 GPa. There is a strong competing conversion pathway under pressure to form the trigonal or tetragonal structure [see Figs. $3(e)$ and $3(f)$; however, the orthorhombic \rightarrow trigonal conversion is more favorable dynamically, similar to the case of BaSi₂ discussed above.

In summary, our *ab initio* calculations have revealed the phase stability and transformation mechanisms for several $BaSi₂$ -type semiconductors. The results show that the tetrahedra in orthorhombic $BaSi₂$ and $SrGe₂$ tend to convert to corrugated layers dynamically under high pressure with bond breaking along the *b*[010] axis, and the Si-corrugated layers in trigonal $BaSi₂$ can further convert to cubic Si nets under low pressure driven by energetics. Moreover, Ge tetrahedra in $BaGe₂$ tend to form a tetragonal-net structure with bond breaking around the *c*[001] axis. The large counterreaction barriers (∼0*.*39 eV) are comparable to those for the compression process reaction barriers (∼0*.*43 eV) for $BaSi₂$, which explains the high stability of the metastable phases under ambient conditions. Our results provide a comprehensive understanding of the experimental findings by unveiling the underlying energetic and kinetic mechanisms, which may shed light on other disilicides and digermanides.

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